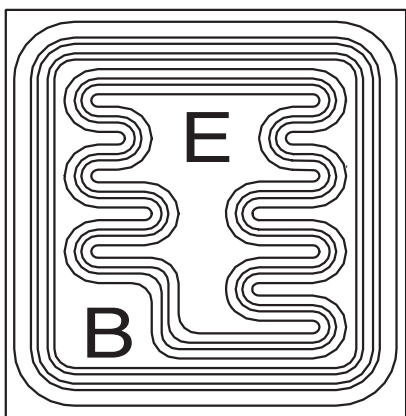


PROCESS DETAILS

| | |
|--------------------------|------------------|
| Process | EPITAXIAL PLANAR |
| Die Size | 16.5 x 16.5 MILS |
| Die Thickness | 9.0 MILS |
| Base Bonding Pad Area | 3.5 x 4.3 MILS |
| Emitter Bonding Pad Area | 3.5 x 4.3 MILS |
| Top Side Metalization | Al - 30,000Å |
| Back Side Metalization | Au - 18,000Å |

GEOMETRY



BACKSIDE COLLECTOR

GROSS DIE PER 4 INCH WAFER

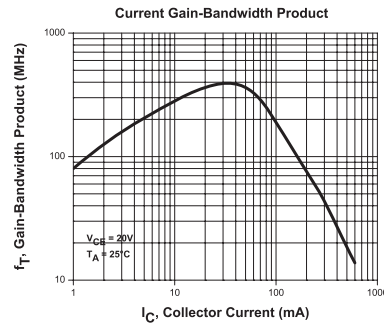
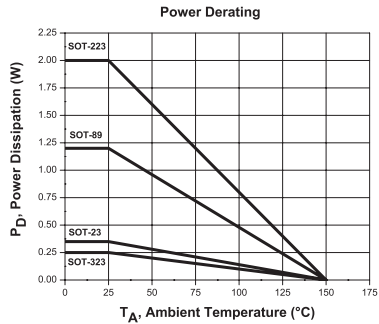
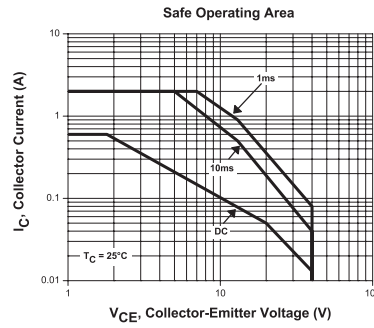
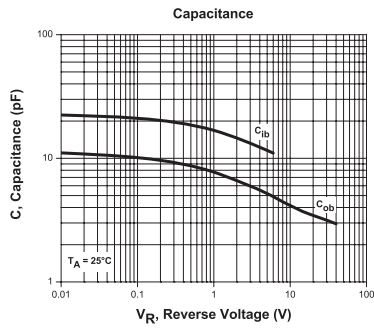
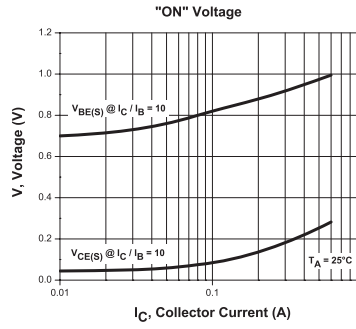
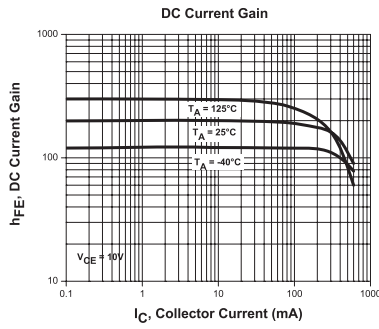
41,690

PRINCIPAL DEVICE TYPES

2N2219A
2N2222A
CMPT2222A
CMST2222A
CXT2222A
CZT2222A
MD2219A
PN2222A

145 Adams Avenue
Hauppauge, NY 11788 USA
Tel: (631) 435-1110
Fax: (631) 435-1824
www.centalsemi.com

R3 (14-August 2006)



145 Adams Avenue
Hauppauge, NY 11788 USA
Tel: (631) 435-1110
Fax: (631) 435-1824
www.centrasemi.com

R3 (14-August 2006)